



Docket No.: 449122030700  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Thomas VOGL

Application No.: 09/675,343

Art Unit: 2825

Filed: September 28, 2000

Examiner: A. Liu

For: **METHOD FOR RECOGNIZING AND  
AVOIDING ETCH-CRITICAL REGIONS**

**RESPONSE AFTER FINAL ACTION**

U.S. Patent and Trademark Office  
2011 South Clark Place  
Customer Window MS AF  
Crystal Plaza Two, Lobby, RM1B03  
Arlington, VA 222002

Dear Sir:

**INTRODUCTORY COMMENTS**

In response to the Office Action dated March 31, 2004, Applicant respectfully requests reconsideration and allowance of the claims in light of the following remarks:

**Remarks/Arguments** begin on page 2 of this paper.